## APPENDIX B

## VERSION WITH MARKINGS TO SHOW CHANGES MADE 37 C.F.R. § 1.121(b)(iii) AND (c)(ii)

## **CLAIMS:**

1. (AMENDED) A substrate method for cleaning a substrate by supplying a cleaning solution thereto, comprising the steps of:

supplying said cleaning solution having ozone dissolved therein to said substrate; and subsequently irradiating said cleaning solution supplied to said substrate with ultraviolet light.

- 9. (AMENDED) A substrate treating apparatus comprising:
- a support [means for supporting] that supports a substrate;
- <u>a</u> cleaning solution supply [means for supplying] <u>that supplies</u> a cleaning solution having ozone dissolved therein to said substrate; [and]

<u>an</u> ultraviolet [emitting means for emitting] <u>emitter than emits</u> ultraviolet light to said substrate; <u>and</u>

[wherein] a control which controls the ultraviolet emitter so that, during a cleaning process in which said cleaning solution is supplied from said cleaning solution supply [means] to said substrate supported by said support [means], said ultraviolet [emitting means] emitter emits ultraviolet light to said cleaning solution supplied to said substrate.

- 10. (AMENDED) An apparatus as defined in claim 9, wherein the ultraviolet light [emitted from said ultraviolet light emitting means] has a wavelength in a range of 242.4 to 300nm.
- 11. (AMENDED) An apparatus as defined in claim 9, wherein said cleaning solution [has a] includes a base[added thereto].

17. (AMENDED) A substrate treating method for removing film from a substrate by supplying a treating solution thereto, comprising the steps of:

supplying said treating solution having ozone dissolved therein to said substrate; and subsequently irradiating said treating solution supplied to said substrate with ultraviolet light.

25. (AMENDED) A substrate treating apparatus for removing film from a substrate by suppying a treating solution thereto, comprising:

<u>a</u> support [means for supporting] <u>that supports</u> said substrate;

<u>a</u> treating solution supply [means for supplying] <u>that supplies</u> said treating solution having ozone dissolved therein to said substrate; [and]

<u>an</u> ultraviolet [emitting means for emitting] <u>emitter that emits</u> ultraviolet light to said substrate; <u>and</u>

[wherein] a control that controls the ultraviolet emitter so that, during a film removing process in which said treating solution is supplied from said treating solution supply [means] to said substrate supported by said support[means], said ultraviolet [emitting means] emitter emits ultraviolet light to said treating solution supplied to said substrate.

26. (AMENDED) An apparatus as defined in claim 25, wherein the ultraviolet light [emitted from said ultraviolet light emitting means] has a wavelength in a range of 242.4 to 300nm.

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